



NANO KOREA 2018

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Deadline for manuscript
submissions:

closed (3 August 2018)

Message from the Guest Editors

This Special Issue will publish selected papers from the 16th International Nanotech Symposium & Nano-Convergence Exhibition (NANO KOREA 2018), 11–13 July, 2018, Goyang, Korea. In particular, the symposium, the largest symposium on nanoscale science and technology in Korea, will be a meaningful occasion to confirm major research results and up-to-date research trends, increase the exchange among researchers in relevant fields, and materialize the results of research. The NANO KOREA symposium will cover the following main topics:

1. Nanoelectronics and photonics
2. Advanced Nanomaterials
3. Nanofabrication and Measurement
4. Nanobiotechnology and Nanomedicine
5. Nanotechnology for Energy
6. Safety, Standardization and Regulation in Nanotechlogy
7. Sensors and Actuators
8. Computational Nano Science and Technology

Papers attracting the most interest at the conference, or that provide novel contributions, will be selected for publication in Micromachines. These papers will be peer-reviewed for validation of research results, developments and applications.





Editor-in-Chief

Message from the Editor-in-Chief

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